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APPLICATION NO.	. Г	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/688,147		10/16/2003	Masayoshi Hiramoto	10873.0805USD1	9228
23552	7590	10/28/2004		EXAMINER	
MERCHANT & GOULD PC				TUGBANG, ANTHONY D	
P.O. BOX 2903 MINNEAPOLIS, MN 55402-0903				ART UNIT	PAPER NUMBER
				3729	3729
				D	

DATE MAILED: 10/28/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)				
		10/688,147	HIRAMOTO ET AL.				
	Office Action Summary	Examiner	Art Unit				
		A. Dexter Tugbang	3729				
Period fo	The MAILING DATE of this communication app or Reply	ears on the cover sheet with the	correspondence address				
A SH THE - External afternal	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. Insions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. In period for reply specified above is less than thirty (30) days, a reply or period for reply is specified above, the maximum statutory period or to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing ed patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be y within the statutory minimum of thirty (30) d vill apply and will expire SIX (6) MONTHS fro , cause the application to become ABANDOI	timely filed lays will be considered timely. om the mailing date of this communication. NED (35 U.S.C. § 133).				
Status							
1)	Responsive to communication(s) filed on 14 Ju	<u>ıly 2004</u> .					
2a)⊠	This action is FINAL . 2b) This	action is non-final.					
3)[Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Dispositi	on of Claims						
5)□ 6)⊠ 7)□	Claim(s) <u>25-30</u> is/are pending in the application 4a) Of the above claim(s) <u>25-27</u> is/are withdraw Claim(s) <u>is/are</u> allowed. Claim(s) <u>28-30</u> is/are rejected. Claim(s) <u>is/are</u> is/are objected to. Claim(s) <u>are</u> subject to restriction and/or	n from consideration.					
Applicati	on Papers						
	The specification is objected to by the Examine						
10)	10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
11)	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
Priority u	ınder 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 09/948,175. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received.							
Attachment	t(s)						
	e of References Cited (PTO-892)	4) Interview Summa					
3) 🔲 Infom	e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/08) r No(s)/Mail Date	Paper No(s)/Mail 5) Notice of Informal 6) Other:	Date Patent Application (PTO-152)				

DETAILED ACTION

Response to Amendment

- 1. The applicant(s) amendment filed on 7/14/04 has been fully considered and made of record.
- 2. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Election/Restrictions

3. As a result of the amendment filed on 7/14/04, this application contains claims directed to the following patentably distinct species of the claimed invention.

Species A, directed to an "oxide target" of Fe and O, Claims 25-27; and Species B, directed to a "compound target" not inclusive of Fe and O, Claims 28-30.

Applicant is required under 35 U.S.C. 121 to elect a single disclosed species for prosecution on the merits to which the claims shall be restricted if no generic claim is finally held to be allowable. Currently, there are no generic claims.

Applicant is advised that a reply to this requirement must include an identification of the species that is elected consonant with this requirement, and a listing of all claims readable thereon, including any claims subsequently added. An argument that a claim is allowable or that all claims are generic is considered nonresponsive unless accompanied by an election.

Upon the allowance of a generic claim, applicant will be entitled to consideration of claims to additional species which are written in dependent form or otherwise include all the limitations of an allowed generic claim as provided by 37 CFR 1.141. If claims are added after

the election, applicant must indicate which are readable upon the elected species. MPEP § 809.02(a).

Should applicant traverse on the ground that the species are not patentably distinct, applicant should submit evidence or identify such evidence now of record showing the species to be obvious variants or clearly admit on the record that this is the case. In either instance, if the examiner finds one of the inventions unpatentable over the prior art, the evidence or admission may be used in a rejection under 35 U.S.C. 103(a) of the other invention.

- 4. Because these inventions/species are distinct for the reasons given above and have acquired a separate status in the art because of their recognized divergent subject matter, restriction for examination purposes as indicated is proper.
- 5. Amended Claims 25-27 are directed to an invention that is independent or distinct from the invention originally claimed for the reasons set forth above.

Since applicant has received an action on the merits for the originally presented invention (i.e. Species B), this invention has been constructively elected by original presentation for prosecution on the merits. Accordingly, Claims 25-27 have been withdrawn from consideration as being directed to a non-elected invention. See 37 CFR 1.142(b) and MPEP § 821.03.

Claim Rejections - 35 USC § 102

- 6. With respect to Claims 28-30, the rejections below are hereby repeated for the applicants' convenience.
- 7. Claims 28 and 29 are rejected under 35 U.S.C. 102(b) as being anticipated by Yokoyama et al 4,889,767.

Regarding Claim(s) 28, Yokoyama discloses a method comprising: forming a magnetic compound film of an oxide ferrite, or oxide ferromagnetic material, by sputtering with a compound target while applying a voltage to a substrate including a plane on which the oxide ferrite is to be formed so as to adjust an amount of oxygen supplied to the oxide ferrite from the oxide target (see col. 16, line 37+). The claimed "compound target" is read as the apparatus shown in Figure 2.

Alternatively, the oxide ferromagnetic material and apparatus (in Fig. 2) of Yokoyama can be alternatively read as the claimed "magnetic compound film" and "compound target", respectively. It is noted that the limitations of "magnetic compound film" and "compound target" (in Claim 28) are considered to be inclusive of the limitations of "oxide ferrite" and "oxide target" (in Claim 25), respectively.

Regarding Claim(s) 29, Yokoyama teaches a bias voltage (see col. 17, lines 16+) applied to the substrate in the oxide target or compound target (apparatus of Fig. 2), which can be broadly read as the claimed "high-frequency bias voltage". It is noted that any voltage taught by Yokoyama can be read as a "high-frequency bias voltage", since the limitations of the claims do not recite any specific voltage values.

Claim Rejections - 35 USC § 103

8. Claim 30 is rejected under 35 U.S.C. 103(a) as being unpatentable over Yokoyama et al in view of Japanese Patent Publication JP 1-239821, referred to hereinafter as JP'821.

Yokoyama discloses the claimed manufacturing method as previously discussed. Yokoyama does not mention that a substrate temperature is heated between 250-700°C.

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JP'821 shows that heating the substrate to a temperature of at least 400°C improves the lamination or bonding characteristics of a coated magnetic material on a substrate (see Purpose and Constitution).

It would have been obvious to one of ordinary skill in the art at the time the invention was made to have modified the method of Yokoyama by providing an elevated substrate temperature, as taught by JP'821, to advantageously improve the laminating and bonding characteristics of the oxide ferrite or magnetic compound film on the substrate.

Response to Arguments

9. Applicant's arguments filed on 7/14/04 have been fully considered but they are not persuasive.

In regards to the merits of Yokoyama et al as applied to Claim 28 above, the applicant(s) assert that Yokoyama does not teach "forming the magnetic compound film by sputtering with a compound target *while* applying a bias voltage to a substrate" (lines 2-3 of Claim 28). It appears that the applicant(s) are saying that "sputtering" and "applying a bias voltage" occur simultaneously or concurrently by placing a great deal of emphasis on the term of "while" above.

The examiner most respectfully disagrees. It is noted that in the rejection above, the examiner stated than any voltage applied by Yokoyama can be read as a "bias voltage" or "high-frequency bias voltage". While it is true that Yokoyama does apply a voltage during a plasma treatment, Yokoyama also applies a voltage during sputtering. Sputtering is a conventional, old and well known technique used in material deposition that explicitly requires a voltage to be applied during deposition. As evidence of this, Yokoyama discusses at least one example where

a voltage is applied concurrently during sputtering (see col. 9, lines 8-44). Here, Yokoyama mentions the use of a DC voltage or a kinetic energy voltage, of which either can be read as a "bias voltage" (line 3 of Claim 28) or a "high-frequency bias voltage" (line 2 of Claim 29) that is applied and present during sputtering. Therefore, the examiner's position is that Yokoyama does fully satisfy the limitations of "forming the magnetic compound film by sputtering with a compound target while applying a bias voltage to a substrate".

Conclusion

10. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

11. Any inquiry concerning this communication or earlier communications from the examiner should be directed to A. Dexter Tugbang whose telephone number is 703-308-7599. The examiner can normally be reached on Monday - Friday 7:00 am - 3:30 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Peter Vo can be reached on 703-308-1789. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

A. Dexter Tugbang Primary Examiner

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October 27, 2004